

FTW



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 1862**
Taku HIRAYAMA et al. : Attorney Docket No. 2005_0892A
Serial No. 10/537,290 : Group Art Unit 1795
Filed June 1, 2005 : Examiner Sin J. Lee
CHEMICAL-AMPLIFICATION TYPE : **Mail Stop: AMENDMENT**
SILICONE-BASED POSITIVE-WORKING
PHOTORESIST COMPOSITION

RESPONSE
THE COMMISSIONER IS AUTHORIZED
TO CHARGE ANY DEFICIENCY IN THE
FEES FOR THIS PAPER TO DEPOSIT
ACCOUNT NO 23-0975

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Official Action dated May 16, 2008, please amend the present application as follows: